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PATENT  
ATTORNEY DOCKET NO.: 053785-5028-01

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:	)	Confirmation No.: 4663
	)	
Se-Jin CHUNG	)	Group Art Unit: 1722
	)	
Application No.: 10/689,030	)	Examiner: F.C. Hiteshew
	)	
Filed: October 21, 2003	)	
	)	
For: EXCIMER LASER CRYSTALLIZATION	)	
OF AMORPHOUS SILICON FILM	)	

Commissioner for Patents  
U.S. Patent and Trademark Office  
Alexandria, VA 22314

Sir:

**RESPONSE TO ELECTION/RESTRICTION REQUIREMENT**


In response to the restriction requirement set forth in the Office Action mailed March 29, 2005, the period for response to which extends through April 29, 2005, Applicant elects the invention defined by the Examiner as Group I, claims 14-18, for examination on the merits.

Except for issue fees payable under 37 C.F.R. §1.18, the Commissioner is hereby authorized by this paper to charge any additional fees during the entire pendency of this application including fees due under 37 C.F.R. §1.16 and 1.17 which may be required, including any required extension of time fees, or credit any overpayment to Deposit Account 50-0310.

Respectfully submitted,

**MORGAN, LEWIS & BOCKIUS LLP**

Dated: April 22, 2005

By:   
David B. Hardy  
Reg. No. 47,362

**Customer No. 009629**  
**MORGAN, LEWIS & BOCKIUS LLP**  
1111 Pennsylvania Avenue, NW  
Washington, DC 20004  
Tel: 202.739.3000  
DBH/fdb  
1-WA/2379221.1